Silylation of Water Glass. IV. Synthesis and Characterization of Silylated Silicic Acids

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Synopsis

Trimethylsilylated (TMSS) and dimethylphenylsilylated silicic acids (DMPS) were prepared via extraction with tetrahydrofuran, started from aqueous sodium silicate. Characterization of these silylates based on the ¹³C and ²⁹Si NMR spectra, X-ray diffraction, gel permeation chromatography, and solution viscosity were conducted to study their molecular structures. It was found that the GPC elution volume was significantly deviated from the calibration curve and also the exponents in solution viscosity vs. molecular weight ($\overline{M_n}$) relationship were very low, almost 0.3. These solution properties suggest that such silylates have compact spherical structures with a high degree of branching, also supported from the other data.

INTRODUCTION

The trimethylsilylated silicic acid (TMSS) was readily prepared by homogeneous reaction of trimethylchlorosilane with the silicic acid in organic media, as was reported in the previous papers.¹⁻³ It was found that the silylates exhibited some excellent properties, particularly, surface properties and thermal stability. However, a serious problem still remained without solution to utilize as plastics, coatings, and/or fibers, that is, very poor film- and fiber-forming properties. This is mainly attributed to the following reasons: low molecular weight, low cohesive force, and structural factor.

Recently, Bechtold et al. intensively studied the polymerization and silvlation of silicic acid generated from not only sodium silicate but also tetraethylsilicate.⁴ They suggested coiled or globular nature of the polymers to explain their limited propensity for film and fiber formation.

In this work, the TMSS and the dimethylphenylsilylated silicic acid (DMPS) derived from aqueous sodium silicate were carefully characterized to obtain their structural information.

EXPERIMENTAL

Preparation of Silylated Silicic Acids

Homogeneous silvlation of silicic acid was described elsewhere.^{1,3}

To 220 mL of 0.64 mol/L H_2SO_4 aqueous solution, 100 mL of 0.80 mol/L aqueous sodium silicate solution (Na₂O·3,32SiO₂, Nippon Chemical Ind., JIS third class) was added with stirring. The solution was mixed with 160 mL of tetrahydrofuran (THF) and allowed to stand for 3 h. Then the solution was separated to two layers on addition of sodium chloride. The THF layer was dried over anhydrous sodium sulfate.

The silicic acid-THF solution was mixed with trimethylchlorosilane or dimethylphenylchlorosilane in a 500-mL three-necked flask. To the solution, excess triethylamine was added as an acid acceptor. After the reaction for given hours, the volatile liquid was evaporated from the solution, followed by addition of water to separate the silylate. The benzene solution of the silylate was filtered through a filter paper to remove the gel, and poured into a methanol-water mixture (85:15 in vol) to precipitate the polymer. The silylate thus obtained was found to still contain silanol group as detected from its IR spectra, and therefore subjected to repeated silylation under the conditions similar to the first run. The silylate was further purified by means of column chromatography using silica gel (Wakogel Q-22) in a column of 2.0 cm diameter and 30 cm length, eluted with *n*-hexane-benzene mixture (9:1 in vol).

Successive solution fractionation of the silylate was conducted as follows: The TMSS and DMPS with molecular weights of 11,900 and 17,200, respectively, were added into the methanol-methyl ethyl ketone mixture at 30°C and allowed to stir magnetically for more than 30 min to equilibrate. Then the turbid solution was filtered through a sintered glass disk. The filtrate was evaporated to obtain the first fraction. The fractionation was further continued by putting the silylate solid into the methanol-methyl ethyl ketone mixture with an increased volume of the latter solvent. Thus, the TMSS and DMPS were divided into 9 and 15 fractions, respectively. The polydispersity factor $(\overline{M_w}/\overline{M_n})$ was almost 1.6 or less by gel permeation chromatography (GPC).

High molecular weight polyphenylsilsesquioxane (PPSQ) was prepared by hydrolysis of phenyltrichlorosilane, followed by polymerization with KOH in diphenylether.⁵

Characterization of Silylates

Analysis of silicon in these silvlates was made by the wet oxidation method with a sulfuric acid-ammonium nitrate oxidant.

¹³C and ²⁹Si NMR spectra were taken in DCCl₃ with a JEOL PFT-100 Fourier transform NMR spectrometer at room temperature (25 MHz for ¹³C and 20 MHz for ²⁹Si).

To measure the number-average molecular weight (M_n) , a Hewlett-Packard 302 Vapor Pressure Osmometer was used at 37°C with toluene. Also the higher $\overline{M_n}$ was determined with a Knauer Membrane Osmometer at 40°C in toluene.

The gel permeation chromatography (GPC) was done with a Shimadzu Liquid Chromatograph 830 having a differential refractive index detector. The columns used here were polystyrene gel (HSG 60, 50, 40, and 30) with THF at 45°C. The elution counts of the chromatograms were calibrated with six monodisperse polystyrenes (Pressure Chemicals Co.).

Limiting viscosity number was measured using a Ubbelohde type viscometer (Fica Viscomatic) with negligible kinetic energy correction at 25°C.

X-ray powder diffraction was measured with a Rigaku D-3C diffractometer (Cu K α radiation) and a Rigaku goniometer SG-7.

RESULTS AND DISCUSSION

The silicic acid-THF solution thus prepared was usually stable to gelation



Fig. 1. Silylate composition, x/(x + y) vs. number-average molecular weight $(\overline{M_n})$: (O) fractionates; (\bullet) unfractionates.

at room temperature even after standing for a week. However, the molecular weight of silicic acid gradually increased with the elapse of time, finally, to form gel. In this experiment, the silicic acid solution was subjected to silylation after storage for 1 day at ca. 5° C.

The silvlation results for the silicic acid are summarized in Table I.

The yield of the silvlates was almost quantitative based on the silicic acid used. The number-average molecular weights $(\overline{M_n})$ ranged from 4000 to 17,000, depending on, mainly, the concentration of reactants and reaction temperature.

The chemical composition of the silylates was determined by means of silicon analysis after repeated silylation. Apparent composition formula of these silylates is assumed to be $[R(CH_3)_2SiO_{1/2}]_x \cdot (SiO_2)_y$, where R is the CH₃ or C₆H₅ group.

Figure 1 shows a relationship of composition and molecular weight $(\overline{M_n})$ in these silvlates.

The fraction of the organic portion, i.e., $R(CH_3)_2SiO_{1/2}$, denoted as x/(x + y), was 0.5 or less, and slightly decreased with $\overline{M_n}$. A similar tendency was observed even for the fractionated samples.

IR spectra were measured to obtain structural information of these silylates. However, strong Si—O—Si asymmetric stretching vibration did not afford it in detail, different from the case of poly(phenylsilsesquioxane) (PPSQ).^{5,6}

Proton-decoupled ¹³C and ²⁹Si NMR spectra of two silvlates and PPSQ are shown in Figures 2(A) and 2(B). Two ²⁹Si peaks in the silvlates were attributed to the organosiloxy Si at lower field and the silica Si derived from silicate at higher field. The silica ²⁹Si peaks around -110 ppm were evidently superimposed on the background ²⁹Si due to the tube. Furthermore, resolution of the silica ²⁹Si peaks were not sufficient to assume the chemical structure of the silica backbone. The half height width of the silica ²⁹Si peaks was much larger than those of PPSQ, trimethylsiloxy, and dimethylphenylsiloxy ²⁹Si by almost twice. This indicates that these silylates contain rigid silica backbones with a high degree of branching.

Figure 3 shows X-ray powder diffraction patterns of PPSQ, TMS, DMPS, and amorphous silica. The amorphous silica used here was made from the silicic

Silylation of Silicic Acid in THF	riethyl- Silylate	amine Temp Time Yield Time of $\overline{M_n}$ (mL) (°C) (h) (g) silvh. (VPO)		35 RT 20 7.0 1 4320	30 RT 0.5 17.6 2 5260	0 70 6 21.3 2 7620	12 70 10 17.9 2 8650	15 70 10 21.5 2 11,900		10 70 2 15.4 2 8160	10 70 2 11.8 2 12,700	15 70 10 24.5 2 17,200
	actants	Chlorosilane THF (mmol) (mL)	(CH ₃) ₃ SiCl	320 50	240 140	160 140 160 140 240 120 $(C_6H_5)(CH_3)_2SiCl$ 55	115 65	91 65	150 120			
	Reacta	Silicic acid [SiO ₂ : g (mmol)]		2.7 (45)	12.0 (200)	12.0 (200)	12.0 (200)	10.3 (170)		5.6 (91)	5.6 (91)	10.3 (171)
		No.		212	103	13 - 16	101 - 102	58ª		35	36	57a

TABLE I Silylation of Silicic Acid in THF



Fig. 2(A). ¹³C NMR spectra of TMSS, DMPS, and PPSQ, 25 MHz, in DCCl₃, 300 mg/mL: (a) TMSS; (b) DMPS; (c) PPSQ.



Fig. 2(B). ^{29}Si NMR spectra of TMSS, DMPS, and PPSQ, 20 MHz, in DCCl₃, 450 mg/mL, doped with Cr(acac)_3.



Fig. 3. X-ray diffraction patterns of PPSQ, TMSS, DMPS, and amorphous silica, 30 kV, 10 mA: (a) PPSQ ($\overline{M_w} = 170,000$); (b) TMSS ($\overline{M_n} = 4320$); (c) DMPS ($\overline{M_n} = 12,700$); (d) DMPS ($\overline{M_n} = 1,570,000$); (e) amorphous SiO₂.

acid-THF solution by evaporating, washing with methanol and water, and heating at 110°C. As can be seen from this figure, the degree of crystallinity in these silvlates was very low. However, their diffraction patterns were similar to those of PPSQ.^{7,8} The d_1 spacings of the silvlates estimated from the first narrower and intenser reflections were observed to lengthen in the following order: PPSQ < TMSS < DMPS. This was probably because of bulkiness of these substituents, i.e., phenyl, trimethylsiloxy, and dimethylphenylsiloxy groups. It was also noted that, as the molecular weight increased, the diffraction patterns became similar to that of the amorphous silica, as shown in Figure 3.

The spacing vs. molecular weight relationship is shown in Figure 4. The d_1 spacing for both TMSS and DMPS increased with the molecular weight to reach almost constant values. Also, the d_1 spacing for the DMPS was found to be slightly larger than that for the TMSS over a wide range of molecular weights. On the contrary, the d_2 spacing for the TMSS was almost constant, regardless of the molecular weight. It was difficult to illustrate the molecular structures for the silylates from the X-ray diffraction data, although it was found that their structural regularity decreased and the silica backbones became larger with an increase of the molecular weight. Accordingly, 3-dimensional structures can be assigned for these silylates.

Figure 5 shows gel permeation chromatograms of the DMPS. All the chromatograms exhibited single, broad, and distorted peaks, similar to those of the TMSS.¹



Fig. 4. Spacings $(d_1 \text{ and } d_2)$ vs. molecular weight $(\overline{M_n})$: $(\mathbf{0}, \mathbf{0})$ TMSS; $(\mathbf{\Delta}, \mathbf{\Delta})$ DMPS; (\mathbf{m}) PPSQ; $(\mathbf{0}, \mathbf{\Delta}, \mathbf{m})$ unfractionates; $(\mathbf{0}, \mathbf{\Delta})$ fractionates.

The $\overline{M_n}$ determined by vapor pressure osmometry (VPO) were about 2.5 times higher than those by the GPC method, which was calibrated by monodisperse polystyrenes. Also, the $\overline{M_n}$ of the fractionated silvlates were found to be always over the calibration curve, as revealed in Figure 6. This apparent discrepancy comes from structural characteristics of the silvlates being of high random branching in the silica backbones.

It is well known that viscosity-molecular weight relationship, $[\eta] = KM^{\alpha}$, is



Fig. 5. Gel permeation chromatograms of unfractionated DMPS THF, concn 10 mg/mL, elution rate 1 mL/min:

		GPC					
<u></u>	$\overline{M_n}$ (VPO)	$\overline{M_n}$	$\overline{M_w}$	$\overline{M_w}/\overline{M_n}$			
а	8186	3190	4140	1.31			
b	12,700	5320	9430	1.77			
с	17,200	6830	32,500	4.76			



Fig. 6. Deviation of GPC elution volume in fractionated DMPS from polystyrene calibration curve.

an effective criterion to assume molecular structure in dilute solutions. Figure 7 shows Mark-Houwink-Sakurada plots of both the silylates in a good solvent, benzene. The limiting viscosity number $[\eta]$ was extremely low over the measured molecular weight ranges. Both the curves for conventional double logarithmic plots were adequately approximated by straight lines, except for the lower molecular weight ranges, less than ca. 5000. The following relationships between $[\eta]$ and $\overline{M_n}$ were established by least squares method: for TMSS

$$[\eta] = 1.24 \times 10^{-1} \overline{M_n}^{0.31}$$
 (cm³/g)



Fig. 7. Mark-Houwink-Sakurada plots of TMSS and DMPS, 25°C, in benzene.



Fig. 8. Limiting viscosity number of DMPS vs. solubility parameter of solvent, 25° C: (a) diisopropylether; (b) *n*-hexane; (c) isoamyl acetate; (d) methyl isobutyl ketone; (e) benzene; (f) *o*-dichlorobenzene.

for DMPS

$$[\eta] = 7.9 \times 10^{-2} \overline{M_n}^{0.34}$$
 (cm³/g)

at 25°C, in benzene

The exponents were almost 0.3, very low compared with those of flexible vinyl polymers $(0.5-0.8)^9$ and syndiotactic PPSQ having rigid rod structure (0.9).¹⁰ This suggests that these silylates exist as compact spheres even in a good solvent. However, it appears that the silylates with molecular weights of lower than 5000 can be considered to be of linear structure to some extent.

The viscosity measurement was further conducted with some solvents having different solubility parameters. Figure 8 represents the plots of viscosity vs. solubility parameter in the DMPS. No significant variation in the viscosity was



Fig. 9. Second virial coefficient (A_2) vs. molecular weight $(\overline{M_n})$, 40°C, in toluene.

observed over the measured range of solubility parameters (6.9–10.0). These solution viscosity behaviors look similar to these of polymethylsiloxanes,^{11,12} although the degree of branching in the silylates might be much higher than that of crosslinked polymethylsiloxanes.

The second virial coefficients (A_2) were estimated from membrane osmometry. The A_2 values were relatively low compared with those of PPSQ¹⁰ and polystyrene¹³ within the molecular weight ranges (56,000–1,570,000). The molecular weight dependence of the A_2 is shown in Figure 9. For both the TMSS and DMPS, the plots fell on a same straight line, roughly expressed in the following equation, having a high negative exponent:

 $A_2 = 10.3 \overline{M_n}^{-1.0}$ (cm³ · mol/g²) at 40°C, in toluene

It was already reported by Audsley and Aveston¹⁴ and Greenberg and Sinclair¹⁵ based on light scattering study that silicic acid in aqueous solution had compact spherical structure. Therefore, it is rather reasonable to presume that the silicic acid molecule in nonaqueous media is also regarded as spherical.

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